EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2587	(electrode) near2 (spaced near2 apart) and (microelectronic workpiece wafer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/15 13:57
L2	185	((electrode) near2 (spaced near2 apart)) and (microelectronic workpiece wafer) and (electrolytic electrolytically electroprocess electroprocess\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/15 13:58
L3	246	(abrasive near2 particle) with (micron) and (CMP)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/15 14:29
L5	4	"7101465".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/15 14:41
S1	2	"6328872".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:13
S2	9372	(((ion adj exchang\$3) (membrane)) and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:35
S3	9372	((ion adj exchang\$3) (membrane)) and (electrolytic eletrolytically electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and ((pd-*20030319*)) (ad<*20030319*)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2008/05/26

S4	6819	[(ion adj exchang\$3) (membrane)) and (electrolytic electrolytically electrochemicall electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and ((@pdc *20030319*) (@adc *20030319*))	US-POPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:45
S5	6819	[(ion adj exchang\$3) (membrane)) and (electrolytic electrolytically electrochemically) near3 electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and ((@pd<"20030319")) [@ad<"20030319"))	US-PGPUB; USPAT; USPOR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:48
S 6	6819	[(ion adj exchang\$3) (membrane)) and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and ((@pdc "20030319") (@adc "20030319")	US-PCPUB; USPAT; USPOR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:48
S7	5546	((ion adj exchang\$3) (membrane)) and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planariz\$10) and (@pd<"20030319")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:49
S8	2170	((ion adj exchang\$3) (membrane)) same (electrolytic electrolytically electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and (@pd<*20030319*)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:50

S9	1231	((ion adj exchang\$3) (membrane)) with (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planarix\$3 planariz\$10) and (@pd<"20030319")	US-PGPUB; USPAT; USCOR; EPO; JPO; DERWENT; IBM_TDB	OR		2008/05/26 11:51
S10	3	((ion adj exchang\$3) (membrane)) with (electrolytic electrolytic electrochemical electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planariz\$10n) and (@pd<"20030319") and (CMP ((chemical chemically) aid (mechanically) aid (mechanically) aid (polish polish\$3 process process\$3 planariz\$3 planariz\$3 planariz\$10n)))	US-PGPUB; USPAT; USCOR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:52
S11	50	((ion adj exchang\$3) (membrane)) same (electrolytically electrochemical electrochemical electrochemicals) near3 (process process\$3 polish polish\$5 planarization) and (@pd<"20030319") and (CMP ((chemical chemically) adj (mechanicall polish\$3 process\$3 planarization)))	US-PGPUB; USPAT; USOCP; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:53
S12	34	(((ion adj exchang\$3) (membrane)).clm. and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization).clm. and (@pd<"20030319") and (mechanical CMP mechanically pad slurry).clm.	US-PGPUB; USPAT; USCOR; EPO; JPO; DEFWENT; IBM_TDB	OR	ON	2008/05/26 11:59

S13	34	((ion adj exchang\$3) (membrane)).clm. and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planariz\$3 planariz\$10n.clm. and (@pdc-"20030319") and (mechanical OMP mechanically pad slurry).clm.	US-PCPUB; USPAT; USOCR; EPO; JPO; DEFIWENT; IBM_TDB	OR		2008/05/26
S14	5	(((ion adj exchang\$3) near2 (membrane), cim. and (electrolytic) elent. and (electrolytic) electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planariz\$3 planariz\$1 and (@pdc-"20030319") and (mechanical OMP mechanically pad slurry),clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:03
S15	0	(((ion adj exchang\$3) near2 (membrane)).clm. and (electrolytic eletrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planarix\$3 planarization).clm. and (@pd<*20030319*).clm.	US-POPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:04
S16	64	(((ion adj exchang\$3) near2 ((membrane)).clm. and (electrolytic elettrolytically electrochemical electrochemically) near3 ((process process\$3 polish polish\$3 planarix\$3 planarization).clm. and ((@pd<*20000319*)	US-PCPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:04
S17	6	((ion adj exchang\$3) near2 (membrane)).clm. and (205/640-686.cds.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:06
S18	855	((ion adj exchang\$3) near2 (membrane)).clm. and ("204" "205").clas.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:07

S19	58	((ion adj exchang\$3) near2 (membrane)).clm. and ("204" "205").clas. and (polish polish \$3 planariz\$3 planarization)	US-PCPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:07
S20	353	((ion adj exchang\$3) catalyst (pure adj water)).clm. and ("204" "205").clas. and (polish polish\$3 planariz\$3 planarization)	US-PCPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:21
S21	23	((ion adj exchang\$3) catalyst (pure adj water)).clm. and ("204" "205").clas. and (polish polish\$3 planariz\$3 planarization) with (pure adj water)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:21
S22	243	((ion adj exchang\$3) catalyst (pure adj water)).clm. and (polish polish\$3 planariz\$3 planarization) with (pure adj water)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:22
\$23	100	((ion adj exchang\$3) catalyst (pure adj water)).dm. and (polish polish\$5] planariz\$3 planarization process process \$3) with (pure adj water) and (electrolytic electrolytically electrochemical) electrochemically near2 (polish polish\$3 planariz\$3 planarization process \$53)	US-PGPUB; USPAT; USCOR; EPO; JPO; DEFWENT; IBM_TDB	OR	ON .	2008/05/26 12:23
S24	47	((ion adj exchang\$3) catalyst (pure adj water).dm. and (polish polish\$5 planariz\$3 planariz\$3 planarization process process \$3) with (pure adj water) and ((electrolytic electrolytically electrochemical electrochemically) near? (polish polish\$3 planariz\$3 planariz\$3) planariz\$3).dm.	US-PCPUB; USPAT; USCOR; EPO; JPO; DEFWENT; IBM_TDB	OR	ON	2008/05/26 12:24

S 25	100	(((ion adj exchang\$3) catalyst (pure adj water), d.m. and (polish polish\$5) planariz\$3 planariz\$3 planarization process process \$3) with (pure adj water) and ((electrolytic electrolytically electrochemical electrochemically) near2 (polish polish\$3 planariz\$3 planarization process process \$53))	US-PCPUB; USPAT; USOCR; EPO; JPO; DEFIWENT; IBM_TDB	OR	ON	2008/05/26 12:24
S26	157	[((ion adj exchang\$3) catalyst) and (pure adj water) and (polish polish\$3 planariz \$3 planarization process process\$3) with (pure adj water) and (electrolytic electrochemically electrochemically) near2 (polish polish\$3 planariz\$3 planarization process process \$3))	US-PGPUB; USPAT; USCOR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:25
\$27	4	"2002047139"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 13:14
S28	6	2002-126400	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 14:05
S29	2	"2002126400"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 14:05
S30	6	"2002012640"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 14:06
S31	15	2002-000838	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 14:06

2000000	S32	3	"20030132103"	US-PGPUB;	OR	ON	2008/05/26
200				USPAT;			14:10
2000				USOOR; EPO;			
2000				JPO;			
2000				DERWENT;			
20000				IBM_TDB			

^{1/15/2009 3:06:33} PM

C:\ Documents and Settings\ NSmith1\ My Documents\ EAST\ Workspaces\ 10549324.wsp